# Preparation and properties of pressureless-sintered porous Si<sub>3</sub>N<sub>4</sub>

Hongjie Wang · Juanli Yu · Jian Zhang · Dahai Zhang

Received: 7 December 2009/Accepted: 11 March 2010/Published online: 30 March 2010 © Springer Science+Business Media, LLC 2010

Abstract Wave-transparent materials used at high temperature environment generated by high supersonic and hypersonic speeds must possess excellent mechanical property. In this paper, porous Si<sub>3</sub>N<sub>4</sub> ceramics with high strength were fabricated by low molding pressure (10 MPa) and pressureless sintering process, without any other pore forming agents. The sintering behavior and the effect of porosity on the mechanical strength and dielectric properties were investigated. The flexural strength of porous Si<sub>3</sub>N<sub>4</sub> ceramics was up to 57–176 MPa with porosity of 45–60%, dielectric constant of 2.35–3.39, and dielectric loss of  $1.6-3.5 \times 10^{-3}$  in the frequency range of 8–18 GHz, at room temperature. With the increase of porosity, the flexural strength, dielectric constant, and dielectric loss all decreased.

## Introduction

Broadband radomes in the high temperature environment generated by high supersonic and hypersonic speeds must possess structural adequacy to withstand severe thermal and aerodynamic loads as well as erosion effects due to rain and dust [1], such as the low dielectric constant, high

J. Zhang  $\cdot$  D. Zhang

mechanical strength, excellent thermal shock resistance, and rain erosion resistance, etc.

In the past years, polytetrafluoroethylene,  $Al_2O_3$ ,  $SiO_2$ , and its composites were all used as radome materials. The applied temperature of polytetrafluoroethylene is lower than 500 °C because of its chemical bonding.  $Al_2O_3$  has rather high strength, high hardness, and good rain erosion resistance. However,  $Al_2O_3$  has relative high dielectric constant, and the dielectric constant increases with the increase of temperature. In the meantime,  $Al_2O_3$  has poor thermal shock resistance. Fused silica (SiO<sub>2</sub>) was used for radome materials owing to its rather low dielectric constant and loss tangent, high chemical stability, high melting point, and extremely low coefficient of thermal expansion [2, 3]. However, it has poor strength (about 50 MPa) and poor rain erosion resistance.

Silicon nitride (Si<sub>3</sub>N<sub>4</sub>) ceramics have excellent mechanical properties (such as high strength, high fracture toughness at both room and elevated temperatures, high thermal shock resistance, and high chemical resistance) [4, 5], and thus it has great promise for high temperature applications. However, Si<sub>3</sub>N<sub>4</sub> ceramics have moderate dielectric constant (5.6–5.8 for reactive sintered Si<sub>3</sub>N<sub>4</sub> and 7.9–8.2 for hotpressed Si<sub>3</sub>N<sub>4</sub> at 8–10 GHz) [6–8], which makes Si<sub>3</sub>N<sub>4</sub> inadequately used for radome materials. At present, porous Si<sub>3</sub>N<sub>4</sub> ceramics with high mechanical strength and low dielectric constant were emphasized.

As we all know, the dielectric constant of air is nearly 1, and its loss tangent is about 0. The introduction of pores gives rise to an effectively reduced dielectric constant, and this lowering is particularly remarkable when the porosity is enhanced to 35% or above. For example, a porous  $Si_3N_4$  ceramic with a porosity of 40–55% attained a low-dielectric constant of 2.7–3.3 [9, 10]. In the meantime, the thermal conductivity can also be lowered because of the existence of

H. Wang (🖂) · J. Yu

State Key Laboratory for Mechanical Behavior of Materials, School of Materials Science and Engineering, Xi'an Jiaotong University, 28 Xian Ning Road, Xi'an 710049, People's Republic of China e-mail: hjwang@mail.xjtu.edu.cn

National Key Laboratory of Advanced Functional Composite Materials, Beijing 100076, China

pores. Therefore, porous ceramics can be generally believed as promising radome materials. But pores in ceramics can also be considered as the crack, which will deteriorate the mechanical properties of materials.

Porous Si<sub>3</sub>N<sub>4</sub> ceramics can be prepared by many approaches including adding pore forming agents [11], foaming [12], the polymeric sponge impregnation [13], freeze drying [14], carbothermal nitridation [15, 16], gel casting [17, 18], etc. Recently, porous Si<sub>3</sub>N<sub>4</sub> ceramics have been fabricated via low temperature sintering, using H<sub>3</sub>PO<sub>4</sub> and H<sub>3</sub>BO<sub>3</sub> as pore forming agent, which had a high strength of 130 MPa with a dielectric constant of 4.6 in the frequency range of 100 MHz to 1 GHz at room temperature [19]. Li [10] fabricated a porous Si<sub>3</sub>N<sub>4</sub>–SiO<sub>2</sub> composite using phenolic resin as pore forming agent, which had a flexural strength of 120 MPa, and a dielectric constant of 3.8 with a dielectric loss of  $3.11 \times 10^{-3}$  at a resonant frequency of 14 GHz [20].

In this work, porous Si<sub>3</sub>N<sub>4</sub> ceramics with the flexural strength of 57–176 MPa, the porosity of 45–60%, and the dielectric constant of 2.35–3.39 were prepared from  $\alpha$ -Si<sub>3</sub>N<sub>4</sub> powder, using Y<sub>2</sub>O<sub>3</sub> and Al<sub>2</sub>O<sub>3</sub> as the sintering aids, at 1600–1800 °C in N<sub>2</sub> atmosphere by low molding pressure (10 MPa) and pressureless sintering. The sintering behavior of porous Si<sub>3</sub>N<sub>4</sub> ceramics and the effect of porosity on the flexural strength and dielectric constant were investigated.

## **Experimental procedure**

## Preparation of porous samples

Si<sub>3</sub>N<sub>4</sub> powders (mean particle size: 0.37 µm,  $\alpha$  phase >94 wt%, Si < 0.5%) were employed in this study and supplied by Shanghai Junyu Ceramics Co. Ltd., Shanghai, China. Al<sub>2</sub>O<sub>3</sub> powders (mean particle size: 1.07 µm, 99% purity, Shanghai Junyu Ceramics Co. Ltd., Shanghai, China) Y<sub>2</sub>O<sub>3</sub> (mean particle size: 4.74 µm, 99.9% purity, Shanghai Yuelong New Materials Co. Ltd., Shanghai, China) were used as the sintering additives. The content of Y<sub>2</sub>O<sub>3</sub> was 5 wt% and Al<sub>2</sub>O<sub>3</sub> was 3 wt% based on the Si<sub>3</sub>N<sub>4</sub> powders, respectively.

The powders were ball-milled in ethanol for 24 h using an agent media to obtain homogeneous slurry. The slurry was dried and sifted out by crushing with a 200 mesh sieve, and then the resultant powder mixture was cold-pressed under 10 MPa using a round steel die. The specimens with a dimension of  $\phi 60 \times 5$  mm were pressureless- sintered at 1600–1800 °C holding for 30–120 min in a N<sub>2</sub> atmosphere (0.225 MPa), and subsequently allowed to cool naturally. In the experiment, the N<sub>2</sub> atmosphere (0.225 MPa) was used only as protecting atmosphere to avoid the volatilization of  $Si_3N_4$  at high temperature.

## Characteristic and test

The porosity of the sintered sample was measured by the Archimedes displacement technique. The bulk density ( $\rho_0$ ) and the true density ( $\rho$ ) of the sintered body were determined by Archimedes' method in water and by water displacement method, respectively. Then the porosity (P) was calculated as follows:

$$P = \left(1 - \frac{\rho_0}{\rho}\right) \times 100\% \tag{1}$$

The room temperature mechanical strength of the sintered specimens was determined by three-point flexural tests. The specimens were machined into test bars shape with a dimension of  $3 \times 4 \times 25$  mm<sup>3</sup>, and all the surfaces of the bars were ground with a 600-grit diamond wheel and edges were beveled. The direction of both the diamond grinding and the beveling was parallel to the bar length. Three-point bending strength was measured on bars using a span of 16 mm and a crosshead speed of 0.5 mm/min (Instron 1195; Instron, UK). By repeating the tests for silicon nitride three times for each specimen, the results are given as the mean values of three measurements.

Phase analysis was conducted by X-ray diffraction (XRD), via a computer controlled diffractometer (XRD-6000; Shimadzu). Fracture surfaces of the sintered bodies were observed using scanning electron microscopy (SEM; S-270; Hitachi) to estimate the microstructure uniformity of the specimens. Pore-size distributions of the sintered bodies were measured using high-pressure porosimeter (Autoscan 33, Quantachrome Corp., USA).

The complex permittivity of porous  $Si_3N_4$  was measured at 8–18 GHz by a resonant cavity method at room temperature, and the dimensions of the test specimens were approximately 54 mm in diameter and 2.3 mm in thickness. The instrument used to determine the complex permittivity was manufactured by the National Key Laboratory of Advanced Functional Composites Materials, Beijing, China.

## **Results and discussion**

#### Porosity and linear shrinkage

The porosity of porous  $Si_3N_4$  ceramics is controlled only by low molding pressure (10 MPa) and pressurelesssintering without the pore forming agent, and thus the purity of the porous  $Si_3N_4$  ceramics is high. Table 1 shows **Table 1**Summary of density,porosity, and shrinkage of thesintered porous  $Si_3N_4$  ceramics

Sintering temperature(°C)	Holding time (min)	Shrinkage (%)	Density (g/cm <sup>3</sup> )	Porosity (%)		
				Total	Open	Closed
1630	60	2.00	1.29	59.5	59.2	0.3
	120	3.86	1.44	54.9	54.5	0.4
1680	60	3.20	1.41	55.7	55.3	0.4
	120	5.16	1.52	52.4	51.9	0.5
1730	60	4.72	1.57	50.8	50.4	0.4
	120	11.26	1.92	39.8	39.4	0.4
1780	30	5.37	1.63	49.4	49.0	0.4
	60	6.03	1.61	45.8	45.7	0.1
	120	12.7	2.03	36.3	35.7	0.6

the influences of sintering temperature on the shrinkage, density, and porosity of sintered porous  $Si_3N_4$  ceramics.

The results show that the total porosity decreases from 59.5 to 45.8%, the linear shrinkage increases from 2 to 6%, and the density increases from 1.29 to 1.61 g/cm<sup>3</sup> with the sintering temperature increasing from 1630 to 1780 °C holding for 60 min. The sintering of Si<sub>3</sub>N<sub>4</sub>-based ceramics is a complex densification process, and phase transformation and grain growth take place simultaneously [20]. The densification of Si<sub>3</sub>N<sub>4</sub> ceramics using Y<sub>2</sub>O<sub>3</sub>-Al<sub>2</sub>O<sub>3</sub> system as sintering aids begins at temperature above 1400 °C [21], at which the glass phase formed and particle rearrangement are the main densification mechanism [22]. And the viscosity of glass phase (sintering aids) is the main factor to influence the densification process. In this experiment, the total content of sintering aids (Y<sub>2</sub>O<sub>3</sub> and Al<sub>2</sub>O<sub>3</sub>) is only 8 wt%, which is lower than that of previous work [23]. The low content of the glass phase (sintering aids), the low viscosity of the glass phase (sintering aids), and pressureless sintering lead to a low linear shrinkage (2-6%) and a little increase of the density (1.29-1.61) with the sintering temperature increasing from 1630 to 1780 °C. Low linear shrinkage indicates that original pores (due to low molding pressure (10 MPa)) in the powder compact remain after sintering, and thus the porous Si<sub>3</sub>N<sub>4</sub> ceramics with porosity (45.8-59.5%) are obtained.

#### X-ray diffraction and microstructure

The XRD patterns of samples sintered at 1680, 1730, and 1780 °C for 60 min are shown in Fig. 1. The content of sintering aids is low, and thus there is no other phase in XRD patterns except for  $\alpha$  or  $\beta$ -Si<sub>3</sub>N<sub>4</sub> phase.

The  $\alpha$ - $\beta$  transformation at temperature of 1680 °C is incomplete, and a large amount of  $\alpha$ -Si<sub>3</sub>N<sub>4</sub> remains in the sample. The formation of  $\beta$ -Si<sub>3</sub>N<sub>4</sub> is enhanced when heating up to higher temperature, heating to 1730 and 1780 °C directly results in the formation of  $\beta$ -Si<sub>3</sub>N<sub>4</sub> single phase, as shown in Fig. 1.



Fig. 1 XRD patterns of the samples sintered at different temperature holding for 60 min

Figure 2 shows the microstructures of samples sintered at 1680, 1730, and 1780 °C for 60 min. The microstructures are uniform, and the  $\beta$ -Si<sub>3</sub>N<sub>4</sub> can be easily identified in SEM micrograph due to its elongated grains. The  $\beta$ -Si<sub>3</sub>N<sub>4</sub> is a high temperature phase and can be formed through dissolution of  $\alpha$ -Si<sub>3</sub>N<sub>4</sub> particles and precipitation as  $\beta$ -phase in a liquid phase. The  $\alpha - \beta$  phase transformation occurs at 1680 °C (Fig. 2a), where large amount of equiaxial  $\alpha$ -Si<sub>3</sub>N<sub>4</sub> and less developed fibrous  $\beta$ -Si<sub>3</sub>N<sub>4</sub> is detected. With the increase of the sintering temperature, it can be seen that the well-developed fibrous  $\beta$ -Si<sub>3</sub>N<sub>4</sub> microstructure is achieved at 1730 and 1780 °C (Fig. 2b, c), this microstructure feature can be obtained by  $\alpha - \beta$  phase transformation in sintering through a solution-precipitation process [24], and these  $\beta$ -Si<sub>3</sub>N<sub>4</sub> are overlapped each other, which makes the samples have higher flexural strength.

Figure 3 shows the influences of sintering temperature on the pore size distribution of porous  $Si_3N_4$  with the same holding time (60 min). It is observed that the pore size is uniform and less than 1 µm, and the samples sintered at lower temperature show a finer pore size distribution.



Fig. 2 SEM micrographs of porous Si<sub>3</sub>N<sub>4</sub> sintered at a 1680 °C, b 1730 °C, and c 1780 °C holding for 60 min



Fig. 3 Pore size distributions of porous  ${\rm Si}_3{\rm N}_4$  at different sintering temperatures holding for 60 min

## Flexural strength

Figure 4 shows the influences of sintering temperature on flexural strength of porous  $Si_3N_4$  ceramics with the same holding time (60 min). The results showed that the flexural

strength of samples increase from 57 to 176 MPa when the sintering temperature varies from 1630 to 1780 °C. The flexural strength variation trends of porous Si<sub>3</sub>N<sub>4</sub> ceramics and density with the sintering temperature are similar, and high flexural strength can be achieved by high density. For Si<sub>3</sub>N<sub>4</sub>-based ceramics, the fibrous-Si<sub>3</sub>N<sub>4</sub> grains overlapped each other could be beneficial for the mechanical properties of the resultant specimens. Using  $\alpha$ -Si<sub>3</sub>N<sub>4</sub> as precursor powder, X-ray diffraction and SEM structural analyses reveal complete phase transformation and fine fibrous  $\beta$ -Si<sub>3</sub>N<sub>4</sub> grains formation by heating the appropriate powder compacts at above 1730 °C (1730 and 1780 °C). Porous Si<sub>3</sub>N<sub>4</sub> ceramics with a microstructure of interconnected fibrous  $\beta$ -Si<sub>3</sub>N<sub>4</sub> grains bonded together have better mechanical properties.

The flexural strength of porous ceramics is very strongly dependent on the porosity. The dependence of flexural strength on porosity has been extensively investigated, and their relationship can be expressed by the following expression [25, 26]:



Fig. 4 The influences of sintering temperature on flexural strength of porous  $Si_3N_4$  ceramics (60 min)



Fig. 5 The relationship between flexural strength and porosity

$$\sigma_{\rm f} = \sigma_0 {\rm e}^{(-np)} \tag{2}$$

where  $\sigma_0$  is the strength at a porosity of 0, *n* is the structural factor, and *P* is the porosity.

Figure 5 shows the relationship between the flexural strength and the porosity of porous  $Si_3N_4$  ceramics. The flexural strength is obviously affected by the porosity, and the flexural strength significantly decreases with the increase of porosity. The porosity increases from 45.7 to 59.5% with the flexural strength decreasing from 175 to 57.6 MPa.

In this article, the formation of pores is relative to low molding pressure (10 MPa), pressureless sintering and the formation of a three dimensional network structure by fibrous  $\beta$ -Si<sub>3</sub>N<sub>4</sub> grains.

#### Dielectric properties

Figure 6 shows the influences of the frequency on the dielectric constant and dielectric loss of porous  $Si_3N_4$  ceramics sintered at 1730 °C for 60 min. It shows that the



Fig. 6 The influences of the frequency on the dielectric constant and dielectric loss  $(\tan \delta)$  of porous Si<sub>3</sub>N<sub>4</sub> ceramics (1730 °C, 60 min)

dielectric constant has minor variation with the change of the frequency (8–18 GHz), the dielectric constant varies from 3.04 to 3.11, the dielectric loss varies from 2.3–  $3.5 \times 10^{-3}$ . Above the frequency of 13 GHz, the tan $\delta$ decreases first and then increases with the increase of the frequency, which may be caused by the water vapor in the pores, similar with reference [27]. According to the dielectric theory, at the low frequency, the influence of the polarization of water is ignorable, but with the frequency increasing, the contribution of the water to the dielectric loss becomes more and more important, which makes the dielectric loss decrease.

Figure 7 shows the influences of porosity on the dielectric constant ( $\varepsilon$ ) and tan $\delta$  of the porous Si<sub>3</sub>N<sub>4</sub>. With the increase of porosity, the  $\varepsilon$  and tan $\delta$  of the porous Si<sub>3</sub>N<sub>4</sub> monotonically decrease.

According to the mixture rule, the dielectric constant of the well-distributed two-phase composite is calculated as follow [28]:



Fig. 7 The influences of the porosity on the dielectric constant ( $\epsilon$ ) and dielectric loss (tan $\delta$ ) of the porous Si<sub>3</sub>N<sub>4</sub> ceramics

$$\varepsilon = V_1 \varepsilon_1 + V_2 \varepsilon_2 \tag{3}$$

where  $\varepsilon$  is the dielectric constant of the composite,  $V_1$  and  $V_2$  are the volume fractions of phase 1 and phase 2,  $\varepsilon_1$  and  $\varepsilon_2$  are the dielectric constant of the two phase, respectively. As porous Si<sub>3</sub>N<sub>4</sub> ceramics, pores are the main phases which influence the composite's dielectric properties. As we all know, the dielectric constant of air is 1 and the dielectric loss is approximately equal to 0, and thus the Eq. 3 can be expressed as follow:

$$\varepsilon = \varepsilon_0 - P(\varepsilon_0 - 1) \tag{4}$$

where  $\varepsilon_0$  is the theoretical dielectric constant of main phase, and *P* is the porosity [29]. Equation 4 shows that the dielectric constant of porous ceramic decreases with the increase of porosity, which is consistent with the results of Fig. 7.

## Conclusions

- (1) Porous  $Si_3N_4$  ceramics with high flexural strength are obtained by low molding pressure (10 MPa) and pressureless sintering process without any other pore forming agents.
- (2) Porous Si<sub>3</sub>N<sub>4</sub> ceramics not only have high mechanical properties but also have low dielectric constant. The flexural strength of porous Si<sub>3</sub>N<sub>4</sub> ceramics varies from 57 to 176 MPa, the porosity varies from 45 to 60%, the dielectric constant varies from 2.35 to 3.39, and the dielectric loss varies from  $1.6-3.5 \times 10^{-3}$  in the frequency range of 8–18 GHz, at room temperature.
- (3) Flexural strength, dielectric constant, and dielectric loss all decrease with the increase of porosity.

Acknowledgements This work was supported by the National Natural Science Foundation of China (90816018), the project of

National Laboratory of Advanced Functional Composite Materials (9140C5602040805), and Xi'an Science and Technology Program (CXY08006(1)).

## References

- 1. Koetje EL, Simpson FH (1987) US Patent 4677443
- 2. Jain V, Varshneya AK, Bihuniak PP (1990) J Am Ceram Soc 73:409
- 3. Kicevic D, Gasic M, Markovic D (1996) J Eur Ceram Soc 16:857
- Kawai C, Matsuura T, Yamakawa A (1999) J Mater Sci 34:893. doi:10.1023/A:1004532200735
- 5. Yang JF, Ohji T, Kanzaki S (2002) J Am Ceram Soc 85:1512
- 6. Ding SQ, Zeng YP, Jiang DL (2007) Mater Lett 61:2277
- 7. Walton JD (1974) Am Ceram Soc Bull 53:255
- 8. Barta J, Manela M, Ficher R (1985) Mater Sci Eng 71:265
- 9. Gota T, Fujii A, Kawai C (2000) US Patent 6091375
- 10. Kawai C, Yamakawa A (2002) J Am Ceram Soc 80:2705
- 11. Lyckfeldt O, Ferreira JMF (1998) J Eur Ceram Soc 18:131
- 12. Fu XP, Qiu FG, Liu XJ (2005) J Inorg Mater 20:1431
- 13. Ramay HR, Zhang MQ (2003) Biomaterials 24:3293
- 14. Fukasawa T, Deng ZY, Ando M (2002) J Am Ceram Soc 85:2151
- 15. Zhang Y, Wang HJ, Jin ZH (2004) Rare Metal Mat Eng 33:655
- 16. Zhang W, Wang HJ, Jin ZH (2005) J Mater Sci Technol 21:894
- 17. Zhang W, Wang HJ, Jin ZH (2005) Mater Lett 59:250
- 18. Yu JL, Wang HJ, Zeng H (2009) Ceram Int 35:1039
- 19. Xia YF, Zeng YP, Jiang DL (2009) Ceram Int 35:1699
- 20. Li XM, Yin XW, Zhang LT et al (2009) Mater Sci Eng A 500:63
- 21. Yang JF, Ohji T, Konda N (2000) J Am Ceram Soc 83:2094
- 22. Yang JF, Zhang GJ, Konda N (2002) Acta Mater 50:4831
- 23. Wang HJ, Wang YL, Jin ZH (1997) J Mater Sci 32:5775. doi:10.1023/A:1018678019734
- 24. Shen ZJ, Zhao Z, Peng H, Nygren M (2002) Nature 417:266
- 25. Coble RL, Kingery WD (1956) J Am Ceram Soc 39:377
- 26. Ryshkewitch E (1953) J Am Ceram Soc 36:65
- 27. Zhang L, Jin H, Cao M (2007) Rare Metal Mater Eng 36:515
- Kingery WD, Bowen HK, Uhlmann DR (1976) Introduction of ceramics. Wiley, USA
- 29. Penn SJ, Alford NM, Templeton A (1997) J Am Ceram Soc 80:1885